## **MATERIAL DECLARATION SHEET**



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Kel	1a	nle	HI	ectronic	Sol	utions

Material	Model 4820T-L
Product Line	Resistor Network
Date	27-December-2005
RoHS Compliant	Yes



No.	Construction Element	Material Group	Material Weight [g]	Materials	CAS If applicable	Average Mass [%]	Sum [%]
1	Element						30.88
		Ceramic	0.12600	Alumina	1344-28-1	30.64	
		Conductor	0.000019	Tantalum Nitride	12033-62-4	0.46	
		Ink	0.000014	Titanium	7440-32-6		
		Glaze	0.000036	Palladium	7440-05-3		
			0.000424	Gold	7440-57-5	0.10	
			0.000331	Copper	7440-50-8	0.08	
			0.000165	Nickel	7440-02-0	0.04	
2	Terminal Pins						6.78
		Copper	0.01071	Copper	7440-50-8	2.61	
		Plating	0.01646	Tin	7440-31-5	4.00	
			0.00060	Silver	7440-22-4	0.15	
			0.00009	Copper	7440-50-8	0.02	
3	Termination						2.47
		Solder	0.00101	Tin	7440-31-5	0.25	
			0.00893	Lead	7439-92-1	2.17	
			0.00020	Silver	7440-22-4	0.05	
4	Body						59.87
		Plastic	0.17150	Silica, Vitreous	60676-86-0	41.70	
			0.04165	Epoxy Cresol Novalic Resin	29690-82-2	10.12	
			0.01715	Phenolic Resin	9003-35-4	4.17	
			0.00611	Antimony Oxide	1309-64-4	1.49	
			0.00980	TBBPA	79-94-7	2.38	
		Total Weight	0.416599				

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Contact person	Cathy Godfrey	Bourns , Inc.		
Bourns location	Riverside, CA	1200 Columbia Ave.		
Phone	Ext. 5008	Riverside, CA 92507 USA		
Fax		phone: 909 781-5690		
e-mail	Cathy_Godfrey@bourns.com	fax: 909 781-5273		

## **Important Remarks:**

- 1. Traces are product parts substances etc. that are below a percentage of 0.1% of total weight.
- 2. A list of the legally regulated substances or materials is available at internet address <a href="http://www.eicta.org/content.asp?pageID=113">http://www.eicta.org/content.asp?pageID=113</a>
- 3. Substances, materials etc. with possible harm to men and environment are listed.
- 4. There are no risks for human beings and to the environment if products are used properly as designated. This shall not apply to risks caused during procedures for disposal etc.
- 5. All statements herein are based on our present knowledge.